Metal-Isolator-Metal Varactor Based on Inkjet-Printed Tunable Ceramics

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Outline



- Introduction
- Inkjet Printing of BST
- Varactor Fabrication
- Prototype and Measurement Results
- Conclusion & Outlook



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Introduction



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- > Multi frequency functionality:
 - Tunable phase shifters
 - Tunable antennas
 - Tunable filters
- > A tunable component can reduce
 - Size
 - Complexity
 - power consumption



Antennas V	$\nabla \nabla \nabla$	$\bigtriangledown \bigtriangledown \bigtriangledown$
Phase Schifters	ØØØ	ØØØ
Feeding Lines		
	Transmitter/Rece	iver

Why BST Thick-Film?







Barium-Strontium-Titanate (BST)

Tunable Dielectric

- Permittivity changes by applying an electrostatic field
- Basic tunable component
 - Tunable Interdigital Capacitor (IDC)
 - Minimum gap 10µm





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Left-hand Transmission Line Phase Shifter



Top view of the manufactured tunable phase shifter
The BST line is printed in the IDCs region.



Phase Shifter Measurement Results



Simulated and measured s-parameter of the phase shifter

The maximum insertion loss is 10dB at 12GHz



EuMA 2013, Nuremberg



Mr. IMP

Component Design Geometry Efficiency







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Limitation of the technology



Tunable phase shifters by using BST thick-film Comp	Advantages	Disadvantages	
	Tuning Speed	High biasing voltage (max 200V)	
	Low power consumption	Low FOM	
	Compact Size	Frequency limitation	
	Compatible with planar structure	Delicate fabrication process	





Limitation of the technology









Limitation of the technology



Metal Isolator Metal Capacitors (MIM):

- Reduce biasing voltage
- Increase breaking voltage
- Increase maximum tunablity
- Improver Insertion Loss
- Decrease number of tunable units



- > MIM Varactor fabricated by selective printed BST film:
 - Top and bottom conductor layer fabricate by Photolithography process
 - BST layer Printed









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➤The inkjet printing technology:

- Selective BST material printing
- Flexible fabrication process
- Simultaneous multi material printing option
- Single nozzle printhead with 100µm orifice diameter







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Degradation of the platinum layers

 The increase in the number of defects in the platinum layer (200nm) on top of Al2O3 substrates (sintered 1h) at different sintering temperatures.





> Past preparation for low sintering BST thick-film:



C. Kohler "Effects of $ZnO-B_2O_3$ Addition on the Microstructure and Microwave Properties of Low-Temperature Sintered Barium Strontium Titanate (BST) Thick Films"



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> 850°C sintered BST inkjet printed line characterization by IDC:

- Topography of an inkjet printed BST line, dried at $T = 50^{\circ}C$ and sintered at $T = 850^{\circ}C$
- Patterned CPW on top of the printed BST line. The minimum gap of the CPW is 10µm.
- CPW line has been measured by on-wafer probes



The characteristics of inkjet printed BST film:



Freq	10GHz	
Permittivity	133	
Tunability	23%(10V/µm)	
Loss Tangent	0.07	



photolithography process

Metal Isolator Metal Capacitors (MIM):

- MIM capacitor by using photolithography process
 - Minimum line wide 10um
 - Cr/Ni as a seed layer because of 850° sintering temperature chrome-nickel/gold (20nm/60nm) seed layer
- Bottom electrode edge angle influence:

AU

Alumina

BST

Electroplating by Positive Photoresist





AU

Alumina

BS



100.00 um

BST





Prototype of The MIM Varactor



Multilayer structure by Metal Isolator Metal (MIM) capacitor

(1.2um bottom layer)

- Alignment was done using a fiducial camera system and alignment markers which were applied together with the bottom electrodes
- GSG with 150µm pitch were used to contact the component







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Measurement Results



> Measurement result of Multilayer structure by Metal Isolator Metal (MIM) capacitor

The biasing voltage has been applied by bias-tee at the RF-port











Conclusion

- The realization and measurements of an inkjet-printed tunable MIM varactor
- The tuning voltage is significantly reduced
- The tunability of 37 % was reached at 20 V biasing voltage (maximum 75%)

Outlook

- The fabricated MIM capacitor demonstrates a simple and flexible preparation
- The quality factor of 8 is achieved at 10GHz which can be increased by reducing conductor and BST layers loss
- Future tunable microwave components based on inkjet printing



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Thank you for your attention

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